



Correction: Inkjet assisted fabrication of planar biocompatible memristors

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Correction for 'Inkjet assisted fabrication of planar biocompatible memristors' by Georgii A. Illarionov *et al.*, *RSC Adv.*, 2019, 9, 35998–36004.

The authors regret that one of the co-authors, Ivan Mukhin, was omitted from the original article. The correct author list is as shown here.

The Royal Society of Chemistry apologises for these errors and any consequent inconvenience to authors and readers.

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